

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2072	carbon adj doped	US-PGPUB; USPAT	OR	ON	2005/12/19 14:21
L2	170665	silicon adj (dioxide or oxide)	US-PGPUB; USPAT	OR	ON	2005/12/19 14:21
L3	693	l1 near3 l2	US-PGPUB; USPAT	OR	ON	2005/12/19 14:21
L4	3095	cdo	US-PGPUB; USPAT	OR	ON	2005/12/19 14:21
L5	3741	l3 or l4	US-PGPUB; USPAT	OR	ON	2005/12/19 14:21
L6	71890	dielectric adj constant	US-PGPUB; USPAT	OR	ON	2005/12/19 14:22
L7	193579	precursor	US-PGPUB; USPAT	OR	ON	2005/12/19 14:22
L8	331	l5 and l6 and l7	US-PGPUB; USPAT	OR	ON	2005/12/19 14:22
L9	806363	substrate	US-PGPUB; USPAT	OR	ON	2005/12/19 14:22
L10	884264	chamber or reactor	US-PGPUB; USPAT	OR	ON	2005/12/19 14:22
L11	227	l8 and l9 and l10	US-PGPUB; USPAT	OR	ON	2005/12/19 14:23
L12	401	l5 near3 (film or layer or coating)	US-PGPUB; USPAT	OR	ON	2005/12/19 14:23
L13	114	l12 and l6 and l7 and l9 and l10	US-PGPUB; USPAT	OR	ON	2005/12/19 14:24
L14	98047	"427"/\$7.ccls.	US-PGPUB; USPAT	OR	ON	2005/12/19 14:24
L15	19	l13 and l14	US-PGPUB; USPAT	OR	ON	2005/12/19 14:29
L16	1	wu adj qingguo.in.	US-PGPUB; USPAT	OR	ON	2005/12/19 14:29
L17	5	fu adj haiying.in.	US-PGPUB; USPAT	OR	ON	2005/12/19 14:30
L18	4	tang adj xingyuan.in.	US-PGPUB; USPAT	OR	ON	2005/12/19 14:30
L19	6	l16 or l17 or l18	US-PGPUB; USPAT	OR	ON	2005/12/19 15:49
L20	0	l5 and l19	US-PGPUB; USPAT	OR	ON	2005/12/19 14:30
L21	1	"6258735".pn. and l6	US-PGPUB; USPAT	OR	ON	2005/12/19 15:51
L22	1	"6258735".pn. and (ic or circuit)	US-PGPUB; USPAT	OR	ON	2005/12/19 15:56